

The derived charge profile is approximately similar so, we can say that the guess was approximately matching

a) · Calculate doping to get Vbi = 0.6 V. at zero bias. Na = 1020/cc (given) ni=10°/cc (ut) Na = 1018 )cc. We have, withholies Vbi = KT ln (Na Nd") = 1.0729 V. We need to reduce Vbi to 0.6 V. Wino = 12 Esi V bi = 3.774 x 10 cm = 37 nm. Lpa= 20nm, W= 20 37nm., Lp < Wdep all pregion is depleted Vmax - from previous analysis: Emax. 1/2 | Emax = 9Nd (Lp/2) => Vmax = 9ND (Lp/2)2 barrier at LP12) height at LP12) + assumed) Vmax 2 Vbi = 0.6 = 9 ND(LP/2) Np = 7.96 × 1018 | cc If there is SiD2 in between 2 n+ layers nr 802 nr band diagram would would look like (out production) physical property SiO2P insulator (large bandgap) La rose no Oxide charges